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(71)Applicant : SHIZUOKA PREFECTURE

NISSEI ELECTRIC CO LTD

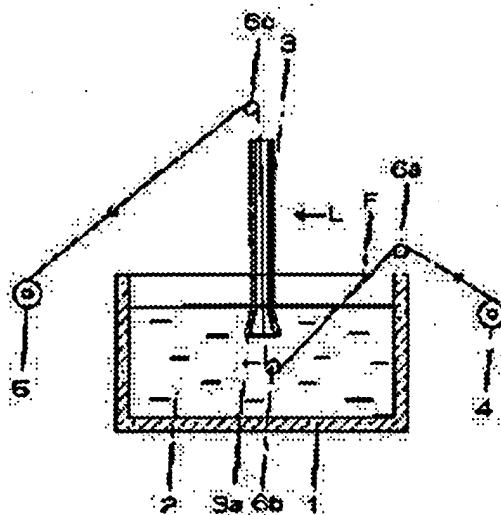
INAGAKI KUNIHIRO

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(72)Inventor : SOFUKAWA TADASHI
TAMURA KATSUHIRO
KANEKO AYUMI
NAKANO MITSUKO
SAITO YUKITAKA
OKUMURA HIDEO
INAGAKI KUNIHIRO**(54) METHOD FOR SURFACE TREATMENT OF FLUOROCARBON RESIN STRAND****(57)Abstract:**

PROBLEM TO BE SOLVED: To enable continuous surface treatment of a fluorocarbon resin to improve the productivity to a great extent while retaining good modification effect on the surface of the fluorocarbon resin.

SOLUTION: In the method for treating the surface of a fluorocarbon strand F by irradiation with an eximer laser beam L in the presence of an ultraviolet-absorbing compound, a quartz capillary 2 is allowed to stand upright in the ultraviolet absorbing compound aqueous fluid 2 in such a manner that one end 3a of the quartz capillary is dipped in the aqueous fluid 2 to fill the inside of the quartz capillary 3 with the aqueous fluid 2 by capillarity, and the fluorocarbon resin strand F which is allowed to be running through the quartz capillary is irradiated with



the excimer laser beam.

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